



Contribution ID: 277

Type: Oral Presentation

Reduction of noise in CSDG MOSFET with HfO₂

Friday, 8 July 2016 11:50 (20 minutes)

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The cylindrical surrounding double-gate (CSDG) MOSFET is an extended version (rotated across one gate) of double-gate MOSFET. It is a hollow cylindrical structure having gate on the external and internal peripheral. With the scaling of device, the gate size and dielectric thickness reduces which leads to large gate-current leakage because of quantum mechanical tunneling of carriers through the thin gate oxide. In the application of traditional MOSFET as switch, various noises are available (such as thermal noise and flicker noise). In the CSDG MOSFET a high dielectric HfO₂ has been used for the oxide.

The CSDG MOSFET has two resistive channels each under external and internal gate. Since the channels (from drain to source) has resistance R_{on1} and R_{on2} , which exhibits *thermal noise* (source of noise) in the small-signal equivalent circuit. This increase in thermal noise may be attributed to hot electrons in short-channel (nanotechnology) devices. This effect can be minimized using the HfO₂ (band gap 6.0 eV) compared to SiO₂ (8.9 eV).

Also, with the use of HfO₂, just below the oxide layer, a resistance creates from source to drain which will be in parallel combination with other oxide resistances. The combination of overall resistance reduces due to parallel combination. Since the noise is proportional to the resistances, hence, the noise with the use of HfO₂ will reduce.

The CSDG MOSFET conduct current near the surface, where surface states act as traps that capture and release current carriers, which generates the flicker noise. Since the *flicker noise* is inversely proportional to the gate oxide capacitance, and with the use of HfO₂, the CSDG MOSFET can achieve higher gate oxide capacitance due to higher value of ϵ .

In conclusion these noises are lower in CSDG MOSFET, for use in nanotechnology devices.

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Session Classification: Theoretical and Computational Physics (1)

Track Classification: Track G - Theoretical and Computational Physics